

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No.: 10/796,170 Confirmation No.: 3493  
Applicant(s): Ogihara, et al.  
Filed: March 9, 2004  
Art Unit: 1711  
Examiner: Irina Sopijia Zemel  
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND  
METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM,  
AND SEMICONDUCTOR DEVICE

Docket No.: 035576/275605  
Customer No.: 00826

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE UNDER 37 C.F.R. § 1.121**

Sir:

In response to the Office Action dated June 20, 2006, please reconsider the above-identified application based on the following:

**Remarks/Arguments** begin on page 2 of this paper.